

(19) United States

(12) Patent Application Publication (10) Pub. No.: US 2024/0215145 A1 SUZUKI et al.

Jun. 27, 2024 (43) **Pub. Date:**

(54) INDUCTIVE COUPLING ANTENNA UNIT AND PLASMA TREATMENT APPARATUS

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- Appl. No.: 18/481,237 (21)
- (22)Filed: Oct. 5, 2023

(30)Foreign Application Priority Data

Dec. 27, 2022	(JP)	 2022-210266
Jun. 2, 2023	(JP)	 2023-091619

Publication Classification

(51) Int. Cl. H05H 1/46 (2006.01)H01J 37/32 (2006.01)

U.S. Cl. CPC H05H 1/4652 (2021.05); H01J 37/3211 (2013.01)

(57) ABSTRACT

An inductive coupling antenna unit is airtightly mounted in an opening provided in a wall of a vacuum chamber. The inductive coupling antenna unit includes: a lid, airtightly covering the opening; an antenna conductor, provided on the lid; and a heating heater, provided on an inner surface of the



